





Measurement of the cluster position resolution of the Belle II Silicon Vertex Detector

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Belle II Silicon Vertex Detector



Standard methods

Cluster Position Resolution is crucial to:

- Provide best quality track reconstruction
- Correctly propagate uncertainty on hit's position to track parameters

Effect of the track extrapolation error subtracted

Residual R: difference between cluster position z and unbiased track position t

R = z - t

Event by event method:

- For each event subtract in quadrature residuals (R) and errors on track extrapolation (δ_t)
- Quantile truncation optimized on simulation to match true resolution
- Resolution σ_{Cl} :

$$\sigma_{Cl} = \sqrt{\langle R^2 - {\delta_t}^2 \rangle}_{trunc}$$



Global method:

Global approach directly compare Residual width and track extrapolation error peak position and width:

$$\sigma_{Cl} = \sqrt{mad(R)^2 - median(\delta_t)^2 - mad(\delta_t)^2}$$

with $mad(y) = 1.4826 \times median(|y - median(y)|)$

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Resolution results: Event by event

Event by event Method:



- Already reach digital resolution in v/N side for both Event by event and Global methods
- Still some room for improvements on u/P side



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Resolution results: Global

Global Method:



- Already reach digital resolution in v/N side for both Event by event and Global methods
- Still some room for improvements on u/P side



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Overlaps method

Overlaps method: [2]

- Select tracks in fiducial area with two hits on the same layer and on consecutive ladders
- Compare residuals computed for the pair of overlapping ladder, double residuals:

 $\Delta R = R_{int} - R_{ext}$

- Apply geometrical correction due to non-parallel sensors
- Resolution is the σ_{68} width of a Student-T distribution fit [p13]

[2] CMS Tracker Collaboration, 'Stand-alone Cosmic Muon Reconstruction Before Installation of the CMS Silicon Strip Tracker', J. Inst., vol. 4, no. 05, May 2009, doi: 10.1088/1748-0221/4/05/P05004.

- b Decouple contribution of tracking precision
- Arginally sensitive to Coulomb scattering
- But low statistic and limited angle range



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Resolution results: Overlaps

Overlaps Method:



- Overlaps method reaches digital resolution with ٠ outermost v/N layers
- Further investigation for better understanding and • possible improvements on u/P side ongoing



Results on collision data from $e^+e^- \rightarrow \mu^+\mu^-$ processes

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Resolution results: Overlaps (II)

Overlaps Method:

	u/P Side		v/N Side	
Layer	Overlaps (µm)	Event by envent (µm)	Overlaps (µm)	Event by event (µm)
3	15.1 +/- 1.1	12.5	33.5 +/- 3.0	16.4
4	17 +/- 0.3	10.4	29.4 +/- 0.7	23.6
5	16 +/- 0.6	10.3	31.7 +/- 1.3	23.6
6	16 +/- 0.6	10.5	36.4 +/- 0.9	23.6

Overlaps method on u/P side sensitive only to a **limited incident track angle range**, differential measurement not possible \rightarrow u/P side comparison applies only in some angular bins of the event by event method (*reported average resolution*)

- Overlaps show larger resolutions than event by event method
- Differential measurement as a function of the incident track angle on v/N side statistically limited



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Summary

Cluster position resolution are estimated with different methods:

Event by event

Global

Overlaps

- Excellent position resolution in agreement with the expectations from the pitch
- Still room for improvement for the u/P side (work ongoing)

Thanks for your attention

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Errors estimation on Event by event & Global methods

Errors estimation in Event by event method:

1. Statistical uncertainties

Taking variance of resolution squared as variance of sample mean

$$\Delta \sigma_{Cl} = \frac{1}{2\sigma_{Cl}} \sqrt{\frac{\langle (R^2 - \delta_t^2)^2 \rangle - \sigma_{Cl}^4}{N}}$$

2. Systematic uncertainties

Adding in quadrature:

- Variation in resolution measurement with and without selection on residual
- Variation in resolution measurement with quantile truncation at ∓0.2% (step) between optimal quantile

Errors estimation in Global method:

- 1. Statistical uncertainties
 - For median $\frac{mad}{\sqrt{N}}$ • For mad $\sqrt{2} \frac{mad}{\sqrt{N-1}}$

2. Systemac uncertainties:

Difference with another robust estimator that should give the same result for Gaussian distributions

- For median |*median midhinge*| (average of the first and third quartiles)
- For mad $|mad \sigma_{68}|$

Detailled Overlaps Method

Method for estimate resolution with overlapping:

- 1. Apply geometical correction factor on double residuals: $\Delta \mathbf{R} = \frac{R_{int} - R_{ext} * C}{\sqrt{1 + C^2}}$ with $C = \frac{\cos a_{ext}}{\cos a_{int}}$
- 2. Fit double residual with a Student-T distribution:



3. The resolution is the σ_{68} of the fitted Student-T distribution T $r = \sigma_{68} (T(X + H - \sigma))$

$$= \frac{\chi_{84}(T(\mathbf{X}, \boldsymbol{\nu}, \boldsymbol{\mu}, \boldsymbol{\sigma})) - \chi_{16}(T(\mathbf{X}, \boldsymbol{\nu}, \boldsymbol{\mu}, \boldsymbol{\sigma}))}{2}$$

True Resoltion in Monte-Carlo:

 $\sigma_{68}(z-x)$

Cluster position x_{Cl} True position x_{True}



Method for estimate resolution uncertainties:

- 1. Vary fitted parameters (N, μ , v, σ) within the fit uncertainties (+/- Fit errors)
- 2. Compute Student-T distribution with new parameters
- 3. Taking σ_{68} resolution of this new model
- 4. Take as resolution uncertainty for each layer half the maximal variation of the recomputed σ_{68} : $\frac{max(r_{\sigma 68}) - min(r_{\sigma 68})}{2}$

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